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Docket Number: 081468-0307331 Client Reference: P-1774.000-US

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re the Application of

VAN SANTEN et al.

Group Art Unit: 2851

Application No.: 10/743,271

Examiner: Unassigned

Filed: December 23, 2003

Confirmation No.: 4441

For: LITHOGRAPHIC APPARATUS AND DEVICE MANUFACTURING METHOD

January 7, 2005

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. 1.56, the attention of the Patent and Trademark Office is hereby directed to the following U.S. patent application(s):

Examiner's Initials	First Inventor	Application No.	Filing Date	Enclosed
¥				一門 前衛 布 奉 奏 答 深
	DUINEVELD et al. (081468-0308101)	10/773,461	02/09/2004	☒ Specification☒ Drawings☒ Other: stamped receipt card
	FLAGELLO et al. (081468-0302644)	10/698,012	10/31/2003	☑ Specification☑ Drawings☑ Other: stamped receipt card
	DIERICHS (081468-0308270)	10/775,326	02/11/2004	☑ Specification☑ Drawings☑ Other: stamped receipt card
	SUWA et al. (Reissue Application of U.S. Patent No. 6,191,429 B1)	10/367,910	02/19/2003	☑ Specification☑ Drawings☐ Other: stamped receipt card

^{*}The Examiner's initials adjacent a citation indicates he/she has considered the cited application relative to the subject application.

It is respectfully requested that these applications and the art cited therein during examination be expressly considered during the prosecution of this application and be made of record in this application. The identification of the above U.S. patent applications is not to be construed as a waiver of secrecy as to those applications now or upon issuance of the present application as a patent.

<u>PLEASE DO NOT PRINT</u> the above information on the patent which results from this application.

Consideration of each listed application is earnestly solicited since unpublished patent applications are contemplated as IDS material; see the exception in Rule 98(a)(2)(iii) and note the penultimate sentence of MPEP 609.

Further, in keeping with MPEP 609, subsec. C(2), 2nd para., line 10 to end of the paragraph (especially note lines 18-25) **PLEASE <u>RETURN</u> A COPY OF <u>THIS LETTER</u>** with the Examiner's initials adjacent each above listing so that applicant will know that each listed application has been considered as required by PTO policy.

Secondly, please consider each document which is listed on the attached Form PTO-1449 and return a copy of that form with the Examiner's initials adjacent each citation, a copy of each document enclosed except for any U.S. patents and published patent applications. It is respectfully requested that these documents listed on the Form PTO-1449 be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed before the mailing date of the first Office Action on the merits in the present application. No certification or fee is required.

Respectfully Submitted,

PILLSBURY WINI HIROP LLF

Jean-Raul Cy Hoffman Registration Number 42663

Customer Number: 00909

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Telephone: (703) 905-2000 Facsimile: (703) 905-2500

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PTO RECEIPT Attorney Docket: 081468-0308101	
Atty: John P. Darling/R. Parra Appin. No: TO BE ASSIGNED Date: February 6, 2004	
Inventor(s): PAULUS CORNELIS DUINEVELD ET AL	
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☐ Preliminary Amendment ☐ Application Data Sheet ☐ Appendix ☐ Utility/Design/Provision ☐ No. of Pages Application (Spec + Claim(s) + Abstract) ☐ No. of Pages Separate Power of Attorney ☐ No. of Numbered Claims Only ☐ Declaration ☐ of pages) ☐ Assignment ☐ Cover Sheet ☐ No. of Priority Documents ☐ No. of Sheets of Drawings (Fig(s) ☐-5) ☐ IDS ☐ Appendix for Cited Appl(s) ☐ Foreign Search ☐ PTO-1449 ☐ Cited Documents ☐ Nonpublicati S ☐ Total Fee Charged to Deposit Account 033975 Other:	PADEMARK OFFICE REPORT/OA
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PTO RECEIPT Attorney Docket: 081468-0308101	
Atty: John P. Darling/R. Parra	
Appln. No: TO BE ASSIGNED Date: February 6, 2004	<u>.</u> .
Inventor(s): PAULUS CORNELIS DUINEVELD ET AL.	
Title: Lithographic Apparatus and Device Manufacturing Method	
☐ Preliminary Amendment ☐ Application Data Sheet ☐ Utility/Design/Provisional	
16 No. of Pages Application (Spec + Claim(s) + Abstract) No. of Pages Separate Power of Attorney	15535 U.S. PTO
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